



Form 1449 (Modified) Information Disclosure Statement By Applicant <small>(Use Several Sheets if Necessary)</small>	Atty Docket No. NOVLP075/NVLS-000820 Applicant: Tipton et al. Filing Date September 26, 2003	Application No.: 10/672,311 Group 2823
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U.S. Patent Documents

Foreign Patent or Published Foreign Patent Application

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
WC	C1	Cho et al., "Method for Porogen Removal and Mechanical Strength Enhancement of Low-K Carbon Doped Silicon Oxide Using Low Thermal Budget Microwave Curing", U.S. Application No. 11/280,113, filed November 15, 2005 (Atty Dkt: NOVLP145/NVLS-3106)

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email: William_Coleman@uspto.gov
Date: 2006-05-11 11:15:44-04:00
Date Considered 05/11/2006

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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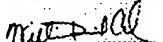
U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
WC	A1	5,849,640	12.1998	Hsia et al.			
WC	A2	6,797,643 B2	09.2004	Rocha-Alvarez et al.			
WC	A3	6,815,373 B2	11.2004	Singh et al.			
WC	A4	6,914,014 B2	07.2005	Li et al.			
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WC	A12	2005/0064698 A1	03.2005	Chang et al.			
WC	A13	6,715,498 B1	04.2004	Humayun et al.			

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation
							Yes No

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication		
WC	C1	U.S. Office Action mailed December 20, 2005, from U.S Application No. 10/849,568 [Atty Dkt No. NOVLP083/NVLS-2867].		
WC	C2	U.S. Office Action mailed January 9, 2006, from U.S Application No. 10/785,235 [Atty Dkt No. NOVLP085/NVLS-2875].		
WC	C3	U.S. Office Action mailed December 27, 2005, from U.S Application No. 10/789,103 [Atty Dkt No. NOVLP094/NVLS-002919].		
WC	C4	U.S. Office Action mailed December 23, 2005, from U.S Application No. 10/800,409 [Atty Dkt No. NOVLP098/NVLS-002907].		
WC	C5	U.S. Office Action mailed February 7, 2006, from U.S Application No. 10/672,305 [Atty Dkt No. NOVLP069/NVLS-000821].		
WC	C6	Subramonium et al., "Pulsed PECVD Method for Modulating Hydrogen Content in Hard Mask", U.S. Application No. 11/318,269, filed December 23, 2005 (Atty Dkt: NOVLP144/NVLS-3102)		
Examiner	 <p>David Coleman USPTO USPTO Date 2006-06-11 19:45:24-04:00</p>		Date Considered	05/11/2006

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Form 1449 (1/2000) (Modified)	Atty Docket No. NOVLP075/NVLS-000820	Application No.: 10/672,311
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U.S. Patent Documents

Foreign Patent or Published Foreign Patent Application

Other Documents

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WC	C1	U.S. Office Action mailed February 28, 2006, from U.S Application No. 10/404,693 [Atty Dkt No. NOVLP064/NVLS-794].
WC	C2	U.S. Office Action mailed March 29, 2006, from U.S Application No. 10/800,377 [Atty Dkt No. NOVLP089/NVLS-002886].
Examiner	Digitally signed by W. David Coleman DN: cn=W. David Coleman, o=USPTO, ou=2523, email=W.D.Coleman@uspto.gov Reason: I have reviewed this document Date: 2006.05.11 10:47:59 -04'07	
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